Search Notes		
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Application/Control No.	Applicant(s)/Patent under Reexamination	
10/679,822	AGARWAL ET AL.	
Examiner	Art Unit	
W. David Coleman	2823	

SEARCHED				
Class	Subclass	Date	Examiner	
438	300 532 573 685	3/2/2005	WDC	
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INTERFERENCE SEARCHED					
Class	Subclass	Date	Examiner		
438	532	3/2/2005	WDD		
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SEARCH NOTES (INCLUDING SEARCH STRATEGY)			
·	DATE	EXMR	
EAST 2.0.1 Applicants form a difusion barrier to fluorine ions on a gate oxide where the diffusion barrier comprises TiBN	3/2/2005	WDC	
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